



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

September 15, 2026

IGI Report Number
Description
Shape and Cutting Style
Measurements

LG835654624
LABORATORY GROWN DIAMOND
ROUND BRILLIANT
9.20 - 9.24 X 5.65 MM

GRADING RESULTS

Carat Weight
Color Grade
Clarity Grade
Cut Grade

3.00 CARATS
F
VS 1
IDEAL

ADDITIONAL GRADING INFORMATION

Polish
Symmetry
Fluorescence
Inscription(s)

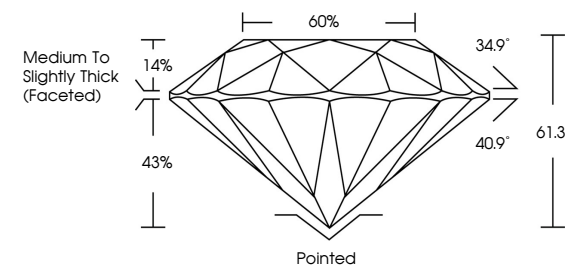
EXCELLENT
EXCELLENT
NONE
IGI LG835654624

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

LG835654624

Report verification at igi.org

PROPORTIONS



Medium To Slightly Thick (Faceted)

60%
34.9°
40.9°
61.3%
Pointed



Sample Image Used

COLOR

FL
Internally Flawless
Very Very Slightly Included
Very Slightly Included
Slightly Included
Included

FL
IF
VVS¹⁻²
VS¹⁻²
SI¹⁻²
I¹⁻³

CLARITY

FL
Internally Flawless
Very Very Slightly Included
Very Slightly Included
Slightly Included
Included

FL
IF
VVS¹⁻²
VS¹⁻²
SI¹⁻²
I¹⁻³

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ROUND BRILLIANT

3.00 CARATS
F
VS 1
IDEAL
61.3%
65%
Medium To Slightly Thick (Faceted)

Pointed
EXCELLENT
EXCELLENT
NONE
IGI LG835654624

Carat Weight
Color Grade
Clarity Grade
Depth
Table
Girdle
Culet
Polish
Symmetry
Fluorescence
Inscriptions(s)

3.00 CARATS
F
VS 1
IDEAL
61.3%
65%
Medium To Slightly Thick (Faceted)
Pointed
EXCELLENT
EXCELLENT
NONE
IGI LG835654624

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa



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